

## EAST Search History

MT.

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L3	1	(first adj insulating adj film and trench and semiconductor near substrate and second adj insulating adj film and third adj insulating adj film and (inner adj walls same trench)).CLM.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	OFF	2006/02/27 09:36